

## PLAGIARISM POLICY - SOHAIL UNIVERSITY

<b>Policy Title:</b>	<b><u>PLAGIARISM POLICY</u></b>
<b>Policy No.:</b>	
<b>Version:</b>	1.0
<b>Prepared by:</b>	Dean Faculty of Basic & Applied Sciences
<b>Approved by:</b>	18 <sup>th</sup> Meeting of Academic Council
<b>Date of Approval:</b>	18-11-24
<b>To be implemented by:</b>	Examination department, Directorate of Postgraduate Programs, Heads of Departments, Registrar Office, ORIC, QEC and Human Resource

### **Preamble:**

This policy aims to foster a culture of originality and respect for intellectual property. It upholds academic integrity and promotes ethical research practices in compliance with the Higher Education Commission (HEC) Anti-Plagiarism Policy-2023 guidelines. Plagiarism is strictly prohibited and encompasses presenting someone else's ideas, words, or works as one's own without proper acknowledgment.

### **Definition of Plagiarism**

Plagiarism includes, but is not limited to:

1. Directly copying text without proper citation.
2. Failing to use quotation marks for directly quoted material.
3. Paraphrasing ideas without attribution.
4. Submitting someone else's work as your own.
5. Misattributing or fabricating sources.

### **Scope of Applicability**

This policy applies to all students, faculty, researchers, and staff of Sohail University covering academic assignments, theses, publications, and research outputs.

### **Detection and Reporting**

- Electronic Detection Systems (EDS) will be used to identify similarities in submitted work.



- A plagiarism complaint may be filed to the Anti-Plagiarism Standing Committee of the University.

### Penalties

Penalties are proportional to the severity of plagiarism (As per HEC-Anti-Plagiarism Policy-2023), ranging from:

- **Minor offenses:** Warnings, mandatory research ethics courses.
- **Moderate offenses:** Failing grades, temporary bans from academic privileges.
- **Major offenses:** Expulsion, termination, or debarment from future opportunities.

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